## AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

- 1. (Currently Amended) A-lasing tunable ring laser device comprising:
- a ring-eavity laser comprising a ring resonator element and an optical gain element that forms part or all of the ring resonator element, the ring resonator element and optical gain element being operable in combination to generate a laser emission at a range of frequencies decided by a resonant frequency of the ring resonator element:
  - a coupling means element for extracting laser emission from the ring-eavity laser; and
  - a frequency selection element means in connection with the coupling means, wherein the

frequency selection means is located outside the ring resonator element, and not forming part of

the ring resonator element, the frequency selection element being connected to the ring resonator

element by way of the said coupling element, and being operable to feed back reflect a part of

the extracted laser emission into the ring eavity resonator element, and to select the frequency of

the feedback signal, and the frequency selection means is not part of the ring cavity said part of

the extracted laser emission;

said frequency selection element incorporating a mechanism for changing the frequency of the reflected light.

 (Currently Amended) The lasting tunable ring laser device as claimed in claim 1, wherein the frequency selection means element is a grating. YU, Siyuan Appl. No. 10/524,049 January 22, 2008

3. (Currently Amended) A lasing deice The tunable ring laser device as claimed in claim

[[1]] 2, wherein the ring-cavity resonator element is an enclosed-comprises a ring-shaped optical

waveguide path.

(Currently Amended) A lasing The tunable ring laser device as claimed in claim 3,

wherein the coupling means element comprises a waveguide-output coupler.

5. (Cancelled)

6. (Currently Amended) A lasing The tunable ring laser device as claimed in claim [[5]]

4, wherein the optical gain element is a semiconductor material.

7. (Currently Amended) The lasing tunable ring laser device as claimed in claim 6,

wherein the waveguide-output coupler is a bi-directional coupler.

8. (Currently Amended) The tunable ring laser lasing device as claimed in claim 7,

wherein the frequency selection means element and the optical gain element are comprised

of comprise an optically passive layer and an optically active layer, a semi-insulating layer, an

upper cladding layer and an ohmic contact layer; and

the frequency selection means element further comprising corrugations formed by an

etching process.

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9. (Currently Amended) The lasing tunable ring laser device as claimed in claim 7,

wherein the optical gain element, the grating, the waveguide output coupler and the ring

resonator element eavity are monolithically integrated onto a substrate.

(Currently Amended) The lasing tunable ring laser device as claimed in claim 9,

wherein the optical gain element is comprised of comprises an optically passive layer and an

optically active layer separated by a spacer layer;

the grating is comprised of comprises a waveguide made from an optically passive layer

and an optically active layer; and

the output waveguide coupler and the ring resonator element eavity are formed in an

optically passive layer.

11. (Currently Amended) The tunable ring laser lasing device as claimed in claim 10,

wherein the grating is formed by periodically varying the width of the waveguide.

12. (Currently Amended) The tunable ring laser lasing device as claimed in claim 10,

wherein the grating is formed by etching corrugations in the waveguide.

13. (Currently Amended) The tunable ring laser lasing device as claimed in claim 7,

wherein the optical gain element, the grating, the output waveguide coupler and the ring

resonator element eavity are hybrid integrated onto a substrate.

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(Currently Amended) The tunable ring laser lasing device as claimed in claim 13,

wherein the substrate material is optically transparent to a lasing wavelength.

15. (Currently Amended) The tunable ring laser lasing device as claimed in claim 1,

wherein the frequency selection element means comprises:

a control element means for controlling a refractive index of the frequency selection

element means.

16. (Currently Amended) The tunable ring laser lasing device as claimed in claim 15,

wherein the control element means is a variable current source.

17. (Currently Amended) The tunable ring laser lasing device as claimed in claim 16,

wherein lasing occurs where a resonant frequency of the ring resonator element eavity is

substantially the same as the reflecting frequency of the frequency selection element means.

18. (Currently Amended) An optical communication system including a tunable ring

laser lasing device as claimed in claim 1.

19. (Currently Amended) A method of changing a lasing frequency of a ring-eavity

laser[[,]] that comprises a ring resonator element and an optical gain element that forms part or

all of the ring resonator element, a coupling element for extracting laser emission from the ring

laser, a frequency selection element located outside the ring resonator element, and not forming

part of the ring resonator element, the frequency selection element being connected to the ring

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resonator element by way of the said coupling element, said frequency selection element incorporating a mechanism for changing the frequency of the reflected light, the method comprising:

generating, through operation of the ring resonator element and the optical gain element that forms part or all of the ring resonator element, a laser emission at a range of frequencies decided by a resonant frequency of the ring resonator element;

resonator element, and not forming part of the ring resonator element, a part of an extracted laser emission into the ring resonator element;

operating the ring-eavity laser at a first ring eavity resonant frequency, wherein a reflecting frequency of the frequency selection element means substantially coincides with the a first ring eavity resonant frequency;

controlling the frequency selection <u>element means</u> to change the reflecting frequency from the first reflecting frequency to a second reflecting frequency; and thereby

operating the ring eavity laser at a second ring eavity resonant frequency, wherein the second reflecting frequency of the frequency selection element means substantially coincides with the second ring eavity resonant frequency.

## 20. Cancelled.

21. (Currently Amended) The method of changing a lasing frequency of a ring eavity laser as claimed in claim 19, wherein the step of controlling the frequency selection element means comprises controlling a refractive index of the frequency selection element means.

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22. (Currently Amended) The method of changing a lasing frequency of a ring eavity

laser as claimed in claim 21, the method further comprising:

reducing a pumping level of an optical gain element to a level less than a lasing threshold

for the duration of changing the frequency selecting  $\underline{\text{element}}_{}$  means from the first reflecting

frequency to the second reflecting frequency; and

restoring the pumping level of the optical gain element to above the lasing threshold after

the change from the first reflecting frequency to the second reflecting frequency.

23. (Currently Amended) The method of changing a lasing frequency of a ring eavity

laser as claimed in claim 22, wherein the frequency selection element means is a grating.

24. (Currently Amended) The method of changing a lasing frequency of a ring eavity

laser as claimed in claim 23, wherein the ring resonator element eavity comprises a ring-shaped

optical waveguide.

25. (Currently Amended) The method of changing a lasing frequency of a ring cavity

laser as claimed in claim 24, wherein the coupling element means comprises a waveguide output

coupler.

26. Cancelled.

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27. (Currently Amended) The method of changing a lasing frequency of a ring eavity

laser as claimed in claim 25 [[26]], wherein the optical gain element is a semiconductor material.

28. (Currently Amended) The method of changing a lasing frequency of a ring eavity

laser as claimed in claim 27, wherein the waveguide output coupler is a bi-directional coupler.

29. (New) A method of selecting the lasing frequency of a ring laser that comprises a

ring resonator element and an optical gain element that forms part or all of the ring resonator

element, a coupling element for extracting laser emission from the ring laser, a frequency

selection element located outside the ring resonator element, and not forming part of the ring

resonator element, the frequency selection element being connected to the ring resonator element

by way of the said coupling element, said frequency selection element incorporating a

mechanism for changing the frequency of the reflected light, the method comprising:

operating the optical gain element that forms part or all of the ring resonator element so

that the ring laser emits a laser emission;

operating the frequency selection element located outside the ring resonator element and

not forming part of the ring resonator element so that its reflection frequency essentially

coincides with a resonant frequency of the ring resonator element.

30. (New) A method of selecting the lasing frequency of a ring laser that comprises a

ring resonator element and an optical gain element that forms part or all of the ring resonator

element, a coupling element for extracting laser emission from the ring laser, a frequency

selection element located outside the ring resonator element, and not forming part of the ring

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resonator element, the frequency selection element being connected to the ring resonator element

by way of the said coupling element, said frequency selection element incorporating a

mechanism for changing the frequency of the reflected light, the method comprising:

operating the optical gain element that forms part or all of the ring resonator element so

that the ring laser emits a laser emission;

operating the reflection frequency selection element located outside the ring resonator

element and not forming part of the ring resonator element so that its reflection frequency

essentially coincides with a first resonant frequency of the ring resonator element, so that the

tunable ring laser device emits essentially at the first resonant frequency of the ring resonator

element;

changing the reflection frequency of the frequency selection element so that its reflection

frequency essentially coincides with a second resonant frequency of the ring resonator element,

so that the ring laser emits essentially at the second resonant frequency of the ring resonator

element.

31. (New) A method of selecting the lasing frequency of a ring laser that comprises a

ring resonator element and an optical gain element that forms part or all of the ring resonator

element, a coupling element for extracting laser emission from the ring laser, a frequency

selection element located outside the ring resonator element, and not forming part of the ring resonator element, the frequency selection element being connected to the ring resonator element

by way of the said coupling element, said frequency selection element incorporating a

mechanism for changing the frequency of the reflected light, the method comprising:

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operating the optical gain element that forms part or all of the ring resonator element so

that the ring laser emits a laser emission;

operating the reflection frequency selection element located outside the ring resonator

element and not forming part of the ring resonator element so that its reflection frequency

essentially coincides with a first resonant frequency of the ring resonator element, so that the

tunable ring laser emits essentially at the first resonant frequency of the ring resonator element;

reducing the gain of the optical gain element to a level less than the lasing threshold of

the ring resonator element for a duration of time, so that the ring laser essentially does not

produce laser emission, and in this duration,

changing the reflection frequency of the frequency selection element so that its reflection

frequency essentially coincides with a second resonant frequency of the ring resonator element,

so that the ring laser emits essentially at the second resonant frequency of the ring resonator

element;

restoring the gain of the optical gain element to above the lasing threshold of the ring

resonator element; wherein

the ring laser emits essentially at the second resonant frequency of the ring resonator

element.

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